

Search Notes

Application/Control No.

09/816,492

Examiner

Toan Ton

Applicant(s)/Patent under
Reexamination

ZHANG, HONGYONG

Art Unit

2871

SEARCHED

| Class | Subclass | Date | Examiner |
|-------|----------|-----------|----------|
| 349 | 42 | 2/28/2005 | TTON |
| | 43 | | |
| | 139 | | |
| | 38 | | |
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INTERFERENCE SEARCHED

| Class | Subclass | Date | Examiner |
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**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

| | DATE | EXMR |
|--|-----------|------|
| EAST liquid crystal thin film transistor overlap\$, overlay\$, overlie\$ pixel light shield\$/block\$, black matrix/mask capacit\$ | 2/28/2005 | TTON |
| counter/common electrode gate/scan\$ bus/line source/drain bus/line insulat\$ | | |
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